

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	6893	plasma same (siloxane bond msq silsesquioxane) and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/18 17:38
L2	1812	1 and plasma same (siloxane bond msq silsesquioxane) same (remov\$3 decompos\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/18 17:30
L3	874	2 and (k dielectric adj constant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/18 17:30
L4	109	3 and plasma same (siloxane bond msq silsesquioxane) same (modif\$4 modification densification densif\$4 harden\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/18 17:32
L5	96	4 not (@rlad>"20040319" @ad>"20040319")	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/08/18 17:33
L6	96	4 not (@rlad>"20040319" @ad>"20040319")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/18 17:33
L7	96	6 and plasma same (siloxane bond msq silsesquioxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/18 17:38